

# Optimization of spin-valve structure NiFe/Cu/NiFe/IrMn for planar hall effect based biochips

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**Abstract:** This paper deals with the planar Hall effect (PHE) of Ta(5)/NiFe(tF)/Cu(1.2)/NiFe(tp)/IrMn(15)/Ta(5) (nm) spin-valve structures. Experimental investigations are performed for  $50\text{ }\mu\text{m}\times 50\text{ }\mu\text{m}$  junctions with various thicknesses of free layer ( $t_F = 4, 8, 10, 12, 16, 26\text{ nm}$ ) and pinned layer ( $t_P = 1, 2, 6, 8, 9, 12\text{ nm}$ ). The results show that the thicker free layers, the higher PHE signal is observed. In addition, the thicker pinned layers lower PHE signal. The highest PHE sensitivity  $S$  of  $196\text{ }\mu\text{V}/(\text{kA}/\text{m})$  is obtained in the spin-valve configuration with  $t_F = 26\text{ nm}$  and  $t_P = 1\text{ nm}$ . The results are discussed in terms of the spin twist as well as to the coherent rotation of the magnetization in the individual ferromagnetic layers. This optimization is rather promising for the spintronic biochip developments. © 2009 IEEE.

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